## **Electronic supplementary Information (ESI)**

## Preparation of Bismuth-doped CsPbBr<sub>3</sub> Perovskite Single Crystal for X-ray and Gamma-ray sensing Application

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Figure. S1. Schematic representation of Bismuth doped on the surface of the CsPbBr<sub>3</sub> single crystal by spin coating process.

In this work, based on precursor engineering, we developed a two-step solution process to prepare the bismuthdoped CspbBr<sub>3</sub> single crystal. The top of the Bil<sub>3</sub> layer was coated on top of the CsPbBr<sub>3</sub> single crystals surface by spin coating (0.2mM Bil<sub>3</sub> solution was prepared by dissolving in 1ml of DMF) solution was used to by spin coating, 800 rpm @ 10 sec, repeated two times after that, dried under a vacuum Oven at 100 °C for 6 hours. This allowed partial cation exchange on the single crystal surface. Also, I<sub>3</sub> has a weak field ligand compared to Br<sub>3</sub>, which makes it difficult to replace the Br<sub>3</sub> atoms in the pure CsPbBr<sub>3</sub> single crystal.





Bandgap energies obtained as a function of Tauc plot analysis from absorbance, the calculated band gap values are 2.46 and 2.41 eV for the pure CsPbBr<sub>3</sub> and Bi-doped CsPbBr<sub>3</sub> single crystal samples, respectively.

Samples	□ <sub>1</sub> (Sec)	□₂ (Sec)	Avg. Lifetime
CsPbBr <sub>3</sub>	6.98 X 10 <sup>-10</sup> [84.08 %]	4.342 X 10 <sup>-9</sup> [15.92 %]	2.67 X10 <sup>-9</sup>
Bi-doped CsPbBr <sub>3</sub>	7.11 X10 <sup>-10</sup> [89.57 %]	4.14 x10 <sup>-9</sup> [10.43 %]	2.25 X10 <sup>-9</sup>

Table. 1 TCSPC lifetime values of the pure CsPbBr<sub>3</sub> and Bi-doped CsPbBr<sub>3</sub> single crystal samples respectively.



Figure S3. Schematic representation of Bi-doped CsPbBr<sub>3</sub> perovskite-based thin film photodetector fabrication.

We fabricated Bi-doped CsPbBr<sub>3</sub> thin films by using single crystals dispersed in DMSO and spin-coated on an FTO substrate. were used in photodetectors with FTO/Bi-doped CsPbBr<sub>3</sub> /Au device structure. Different layers of the device were deposited on the pre-cleaned FTO-coated glass slides. The Bi-doped CsPbBr<sub>3</sub> (photosensitizer) single crystals were dispersed in DMSO: DMF. After that, the solution was deposited by spin coating method over the FTO with 800 rpm at 20 seconds, repeated at two times, and dried at ambient temperature for 3 hrs. Au top electrodes was deposited (electrode area (0.25×0.25 cm<sub>2</sub>) by using thermal evaporation method. The constructed devices were subjected to photocurrent measurements.



**Figure. S4**. (a) Room-temperature X-ray diffraction pattern of CsPbBr<sub>3</sub> and Bi-doped CsPbBr<sub>3</sub> single crystal thinfilm samples coated on FTO substrate.

The XRD characterization explores the structural authentication of thinfilm, crystallographic planes, and crystallinity. The powder XRD patterns of synthesised pure CsPbBr<sub>3</sub> and Bi-doped CsPbBr<sub>3</sub> perovskite thin film coated on FTO substrate are shown in **Fig. S4**. As a result, the 20 peaks were found to be 15.46°, 27.31°, 30.93°, and 64.11° and corresponding planes of (110), (111), (220), and (440) for both CsPbBr<sub>3</sub> and Bi-doped CsPbBr<sub>3</sub> perovskite thin films single crystal thin films samples, which are in good agreement with a single crystal. The CsPbBr<sub>3</sub> perovskite thin films exhibit an orthorhombic structure (ICSD 97851) with the Pnma space group, and there is no phase change occurring in the thin film formation.



**Figure S5.** Time-dependent photocurrent spectra of Bi-doped  $CsPbBr_3$  thin-film photodetectors at bias 5V and 2V under different wavelength LED source 470 nm and 530 nm (The LED source intensity with 0.3 A input power).

The photoresponsivity (R) is the ratio of the photogenerated current density to that incident light (at given (wavelength)  $\lambda$ ~470 nm and 530 nm.

$$R = \frac{\Delta I}{PA}$$

Where  $\Delta I$  is the corresponding change in dark and illuminated current and P is the light's power density (or illumination intensity). The value of the responsivity is calculated for the photodetector at two different wavelength and tabulated in Table.1

S.No	Wavelength	I <sub>ON</sub> /I <sub>OFF</sub> ratio	Responsivity
	(nm)		(mA/w)
1.	470	596	0.35
2.	530	24	0.25

Table. 2 Calculated value of the responsivity of the Bi-doped CsPbBr<sub>3</sub> thin film sample at 5v bias.